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DESCRIPTION

This volume compiles essential contributions to the most innovative fields of Plasma Processes and Polymers. High-quality contributions cover the fields of plasma deposition, plasma treatment of polymers and other organic compounds, plasma processes under partial vacuum and at atmospheric pressure, biomedical, textile, automotive, and optical applications as well as surface treatment of bulk materials, clusters, particles and powders.

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ABOUT THE AUTHOR

The editors are leading scientists worldwide, well known from their publications, their work as editors as well as from conference organizations

* Dr. Riccardo d’Agostino, Professor, Director of the Department of Chemistry, University of Bari, Italy
* Dr. Michael R. Wertheimer, Professor, NSERC Industrial Research Chair on Low Pressure Plasma Processing of Materials, Ecole Polytechnique, Montreal Canada

* Dr. Christian Oehr, Head of Dept. Interfacial Engineering, Fraunhofer Institute for Interfacial Engineering and Biotechnology, Stuttgart, Germany

* Dr. Pietro Favia, Associate Professor, Department of Chemistry, University of Bari

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